

# Journal of MATERIALS RESEARCH

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## Journal of MATERIALS RESEARCH

2997–3008 The Snomipede: A parallel platform for scanning near-field

### Volume 26, Number 24, December 28, 2011

### **INVITED FEATURE PAPER**

	photolithography	Yuan Zhang, Shahrul A. Alang Ahmad, Lu Shin Wong, Jamie K. Hobbs, Graham J. Leggett, Jason Micklefield, Clive J. Roberts, John M.R. Weaver
ARTICLES		
3009–3019	Current-induced interfacial reactions in Ni/Sn–3Ag–0.5Cu/Au/Pd(P)/Ni–P flip chip interconnect	M.L. Huang, S. Ye, N. Zhao
3020–3031	Structure-property-performance of nanocomposite Cr–Si–N films synthesized by a duplex surface treatment technique	Daohui Lai, Jiang Xu, Zong-Han Xie, Paul R. Munroe
3032–3037	Intermetallic compound spalling characteristics of Sn-3.5Ag solder over ternary electroless Ni under-bump metallurgy	Dong Min Jang, Jin Yu
3038–3043	Miscibility gap and thermoelectric properties of ecofriendly ${\rm Mg_2Si_{1-x}Sn_x}$ (0.1 $\le x \le$ 0.8) solid solutions by flux method	Luxin Chen, Guangyu Jiang, Yi Chen, Zhengliang Du, Xinbing Zhao, Tiejun Zhu, Jian He, Terry M. Tritt
3044–3050	A critical evaluation of reactive templated grain growth (RTGG) mechanisms in highly [001] textured $Sr_{0.61}Ba_{0.39}Nb_2O_6$ ferroelectric-thermoelectrics	Yunfei Chang, Soonil Lee, Stephen Poterala, Clive A. Randall, Gary L. Messing
3051–3057	Structural characterization of B-doped diamond nanoindentation tips	David J. Sprouster, Simon Ruffell, Jodie E. Bradby, James S. Williams, Mark N. Lockrey, Matthew R. Phillips, Ryan C. Major, Oden L. Warren
3058–3064	Synthesis, morphology, and magnetic properties of NiCo/carbon nanocomposites	Meihua Xu, Wei Zhong, Chaktong Au, Liya Lv, Youwei Du
3065–3071	Ultrafast self-catalytic growth of silicon carbide nanowires	Andrzej Huczko, Agnieszka Dąbrowska, Michał Soszyński, Natalia Maryan, Michał Bystrzejewski, Piotr Baranowski, Hubert Lange, Thomas Gemming, Alicja Bachmatiuk, Mark Rümmeli
3072–3082	Processing of multilayer microcrystalline and nanocrystalline diamond thin films using Ar-rich microwave plasmas	Nirmal Govindaraju, Chaitanya Kane, Raj N. Singh
3083–3090	Direct formation of nanostructured graphitic carbon from an acrylic ion-exchange resin at 600°C	Guoqiang He, Xueming Ma, Zhengbing Xu, Zaoxue Yan, Hui Meng, Pei K. Shen
3091–3097	Synthesis and catalysis properties of NiO flower-like spheres and nanosheets: Water-induced phase transformation of nickel hydroxides	Xin Liang, Junjia Xiao, Ye Gou, Biaohua Chen

Ehtsham ul-Haq, Zhuming Liu,

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3098–3106	Anelastic recovery of pure magnesium quantitatively evaluated by acoustic emission	Yunping Li, Manabu Enoki
3107–3115	The long-term corrosion of mild steel in depassivated concrete: Localizing the oxygen reduction sites in corrosion products by isotopic tracer method	Emilien Burger, Judith Monnier, Pascal Berger, Delphine Neff, Valérie L'Hostis, Stéphanie Perrin, Philippe Dillmann